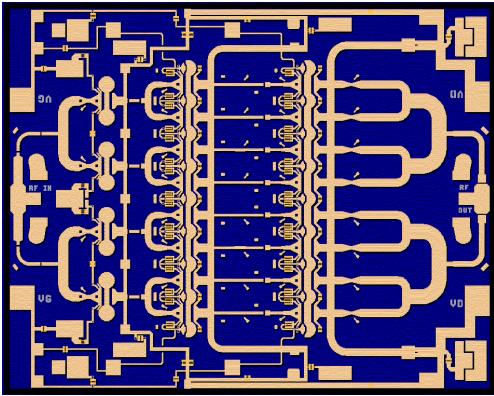
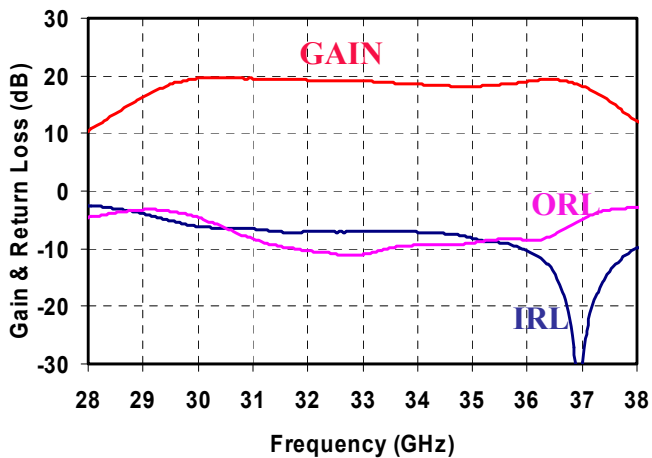


2 Watt Ka-Band Power Amplifier

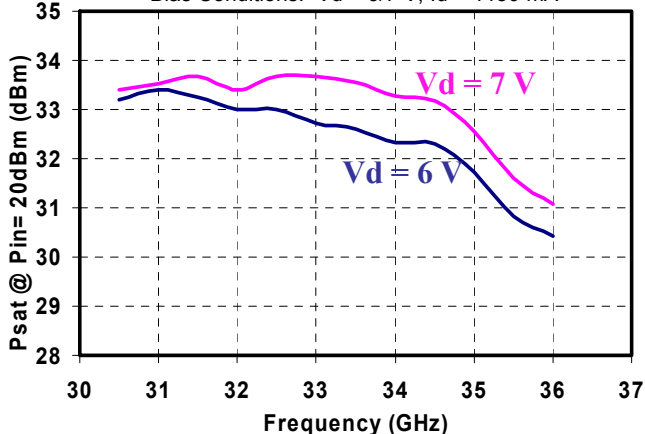


Measured Performance

Bias Conditions: $V_d = 6\text{ V}$, $I_d = 1150\text{ mA}$



Bias Conditions: $V_d = 6/7\text{ V}$, $I_d = 1150\text{ mA}$



Key Features

- Typical Frequency Range: 31 - 35 GHz
- 33.5 dBm Nominal P_{sat} @ $V_d = 7\text{ V}$
- 31.5 dBm Nominal P1dB
- IMD3: 31dBc at $P_{out}/\text{tone}=22\text{ dBm}$
- 18 dB Nominal Gain
- Bias 6 - 7 V, 1150 mA
- 0.25 μm 2MI pHEMT Technology
- Chip Dimensions 4.0 x 3.2 x 0.1 mm
(0.161 x 0.128 x 0.004) in

Primary Applications

- Point-to-Point Radio
- Military Radar Systems
- Ka Band Sat-Com

Product Description

The TriQuint TGA4514 is Power Amplifier for Ka-band applications. The part is designed using TriQuint's proven standard 0.25 μm gate Power pHEMT production process.

The TGA4514 provides a nominal 33.5 dBm of output power at an input power level of 20 dBm with a small signal gain of 18 dB. Nominal IMD3 is 31dBc at P_{out}/tone of 22 dBm.

The part is ideally suited for low cost markets such as Point-to-Point Radio and Ka-band Sat-Com.

Datasheet subject to change without notice.

Table I
Absolute Maximum Ratings 1/

| Symbol | Parameter | Value | Notes |
|----------|-----------------------------|--------------|-----------|
| Vd-Vg | Drain to Gate Voltage | 13 V | |
| Vd | Drain Voltage | 8 V | <u>2/</u> |
| Vg | Gate Voltage Range | -5 to 0 V | |
| Id | Drain Current | 2.5 A | <u>2/</u> |
| Ig | Gate Current Range | -9 to 210 mA | |
| Pin | Input Continuous Wave Power | 27 dBm | <u>2/</u> |
| Tchannel | Channel Temperature | 200 °C | |

1/ These ratings represent the maximum operable values for this device. Stresses beyond those listed under “Absolute Maximum Ratings” may cause permanent damage to the device and / or affect device lifetime. These are stress ratings only, and functional operation of the device at these conditions is not implied.

2/ Combinations of supply voltage, supply current, input power, and output power shall not exceed the maximum power dissipation listed in Table IV.

Table II
Recommended Operating Conditions

| Symbol | Parameter <u>1/</u> | Value |
|----------|------------------------------|---------|
| Vd | Drain Voltage | 6 V |
| Id | Drain Current | 1150 mA |
| Id_Drive | Drain Current under RF Drive | 1500 mA |
| Vg | Gate Voltage | -0.45 V |

1/ See assembly diagram for bias instructions.

Table III
RF Characterization Table

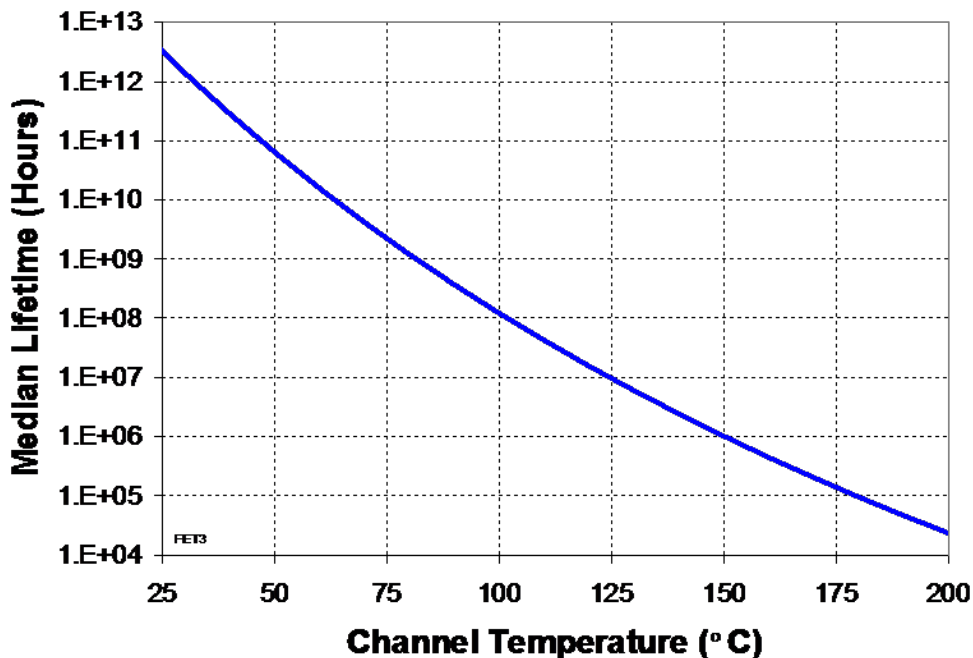
Bias: Vd = 6 V, Id = 1150 mA, Vg = -0.45 V Typical

| SYMBOL | PARAMETER | TEST CONDITIONS | NOMINAL | UNITS |
|---------------|---|------------------------|----------------|--------------|
| Gain | Small Signal Gain | F = 31 - 35 GHz | 18 | dB |
| IRL | Input Return Loss | F = 31 - 35 GHz | -7 | dB |
| ORL | Output Return Loss | F = 31 - 35 GHz | -10 | dB |
| Psat | Saturated Output Power @ Pin = 20dBm | F = 31 - 35 GHz | 32.5 | dBm |
| P1dB | Output Power @ 1dB Gain Compression | F = 31 - 35 GHz | 32 | dBm |
| IMD3 | IMD3 @ Pout/Tone = 22dBm, Freq = 33GHz | F = 31 - 35 GHz | 31 | dBc |

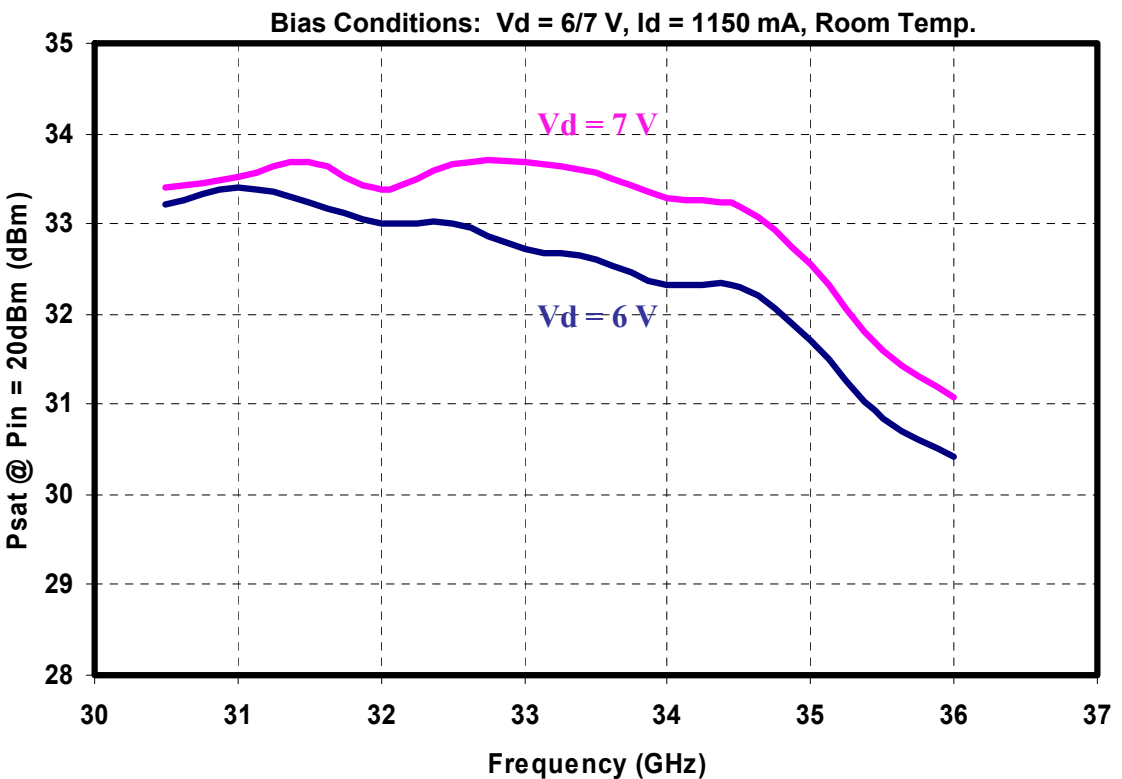
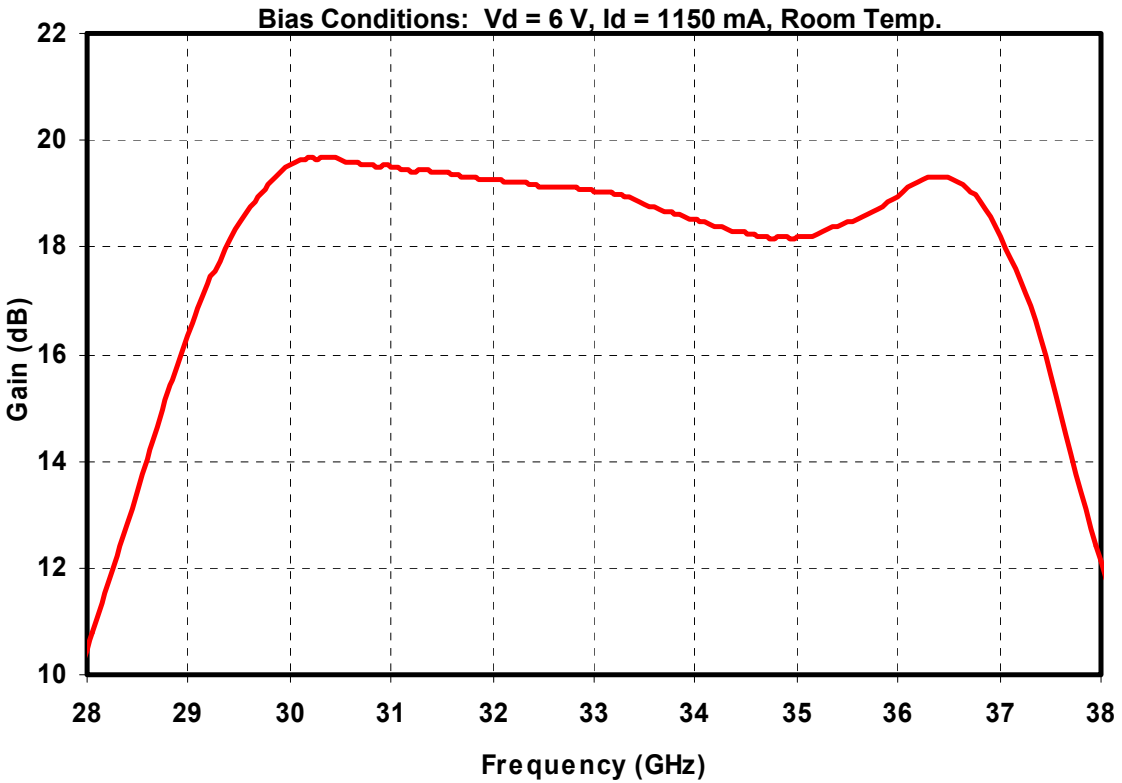
Table IV
Power Dissipation and Thermal Properties

| Parameter | Test Conditions | Value |
|---|--|---|
| Maximum Power Dissipation | Tbaseplate = 70 °C | Pd = 10 W Tchannel = 199 °C |
| Thermal Resistance, θ_{jc} | Vd = 6 V Id = 1.15 A Pd = 6.9 W Tbaseplate = 70 °C | θ_{jc} = 11.5 °C/W Tchannel = 149 °C Tm = 1.1E+6 Hrs |
| Thermal Resistance, θ_{jc} Under RF Drive @ 33GHz | Vd = 6 V Id = 1.45 A Pout = 32.5 dBm Pd = 6.9 W Tbaseplate = 70 °C | θ_{jc} = 11.5 °C/W Tchannel = 149 °C Tm = 1.1E+6 Hrs |
| Mounting Temperature | 30 Seconds | 320 °C |
| Storage Temperature | | -65 to 150 °C |

Median Lifetime (Tm) vs. Channel Temperature

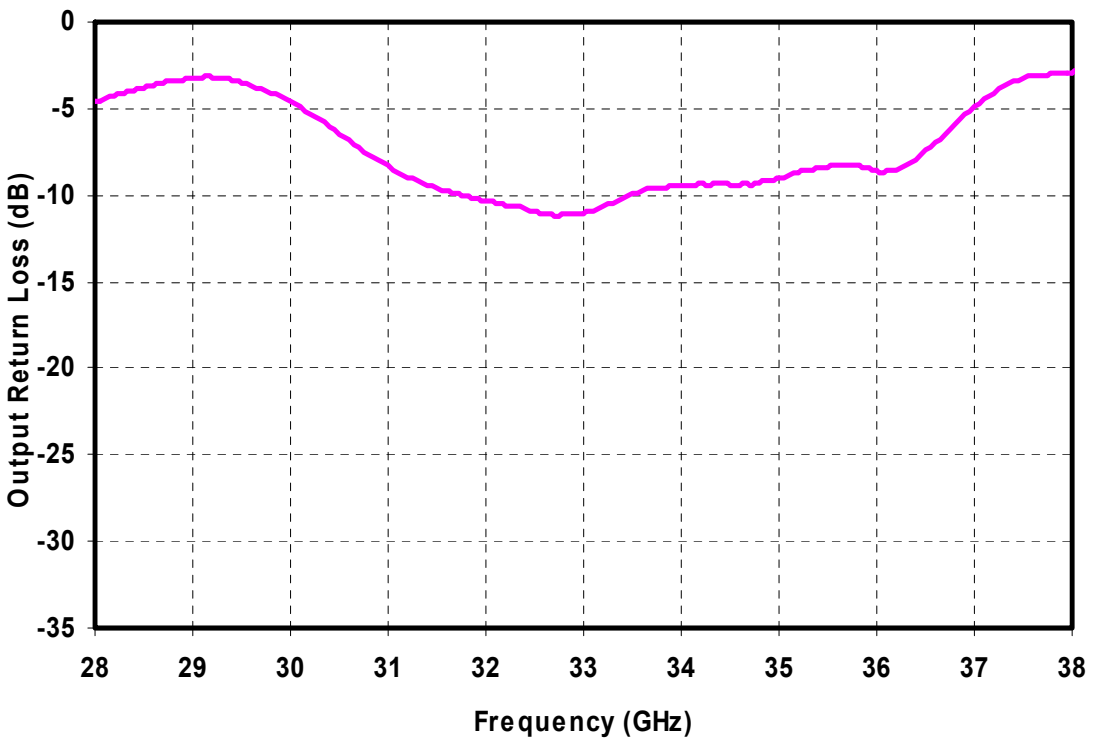
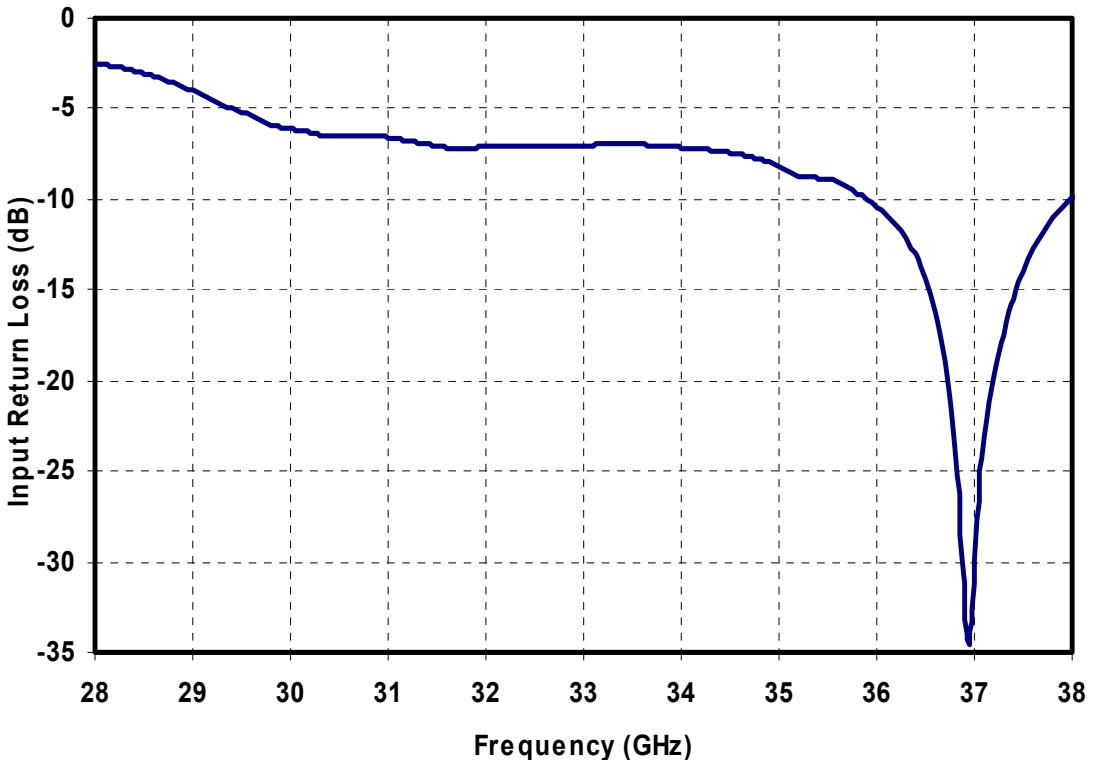


Measured Data

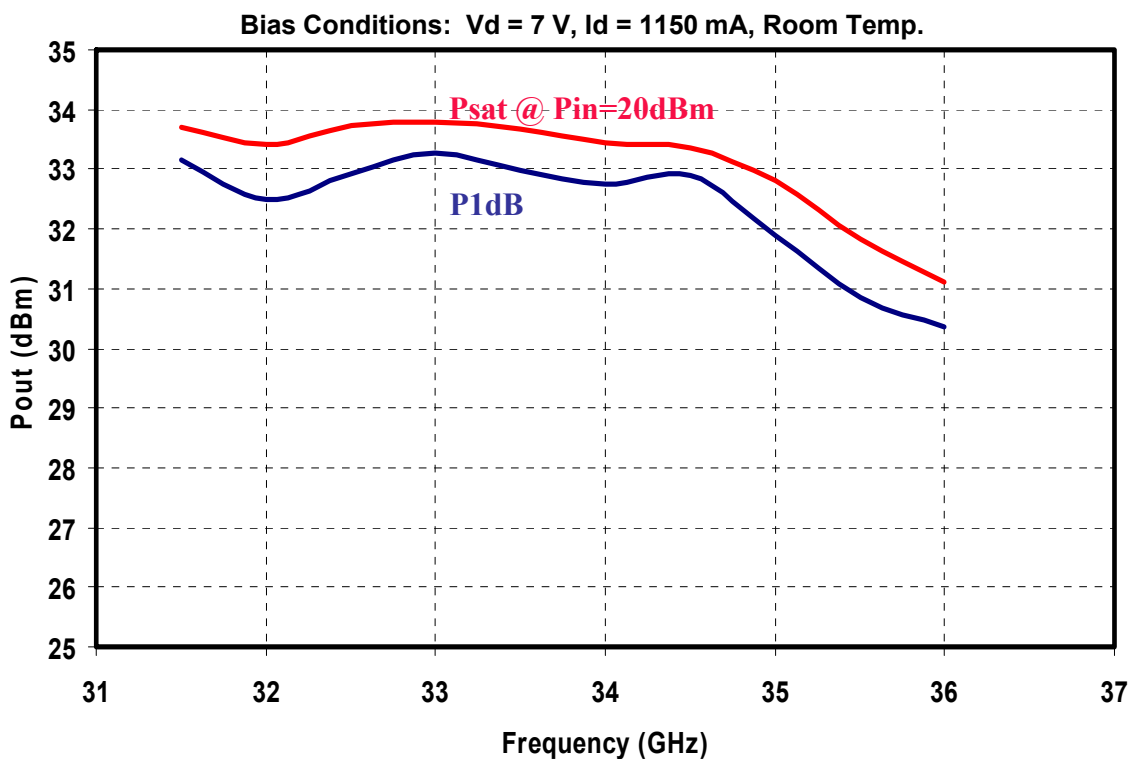
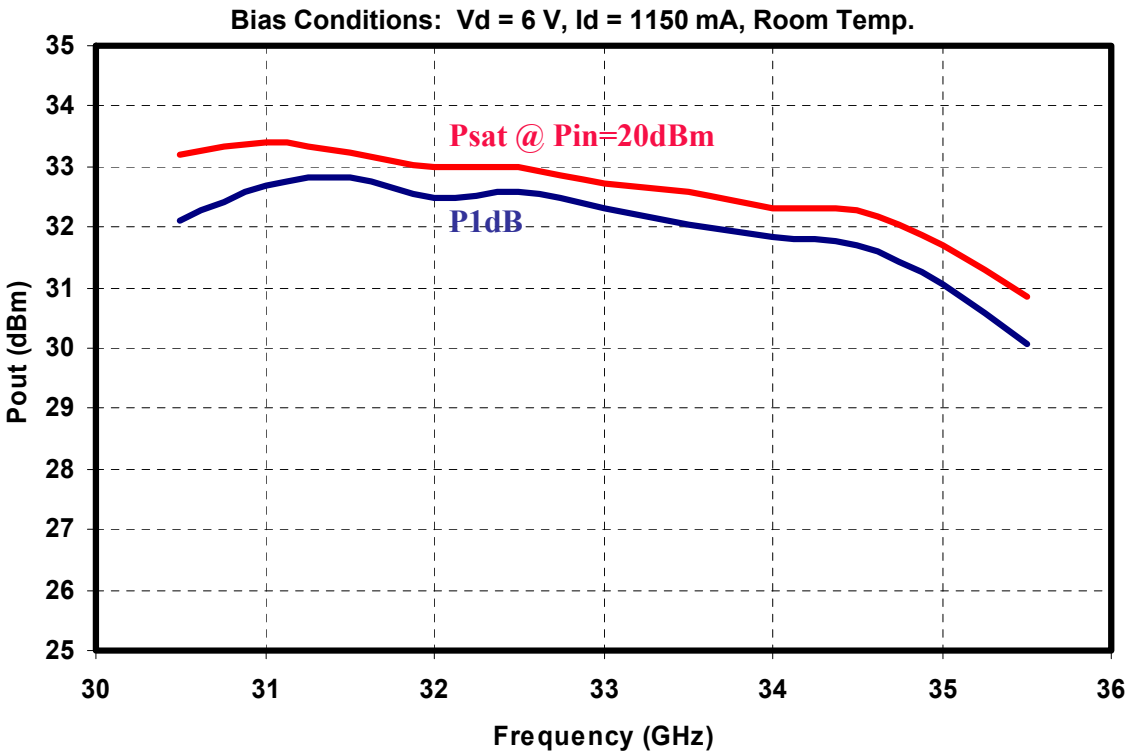


Measured Data

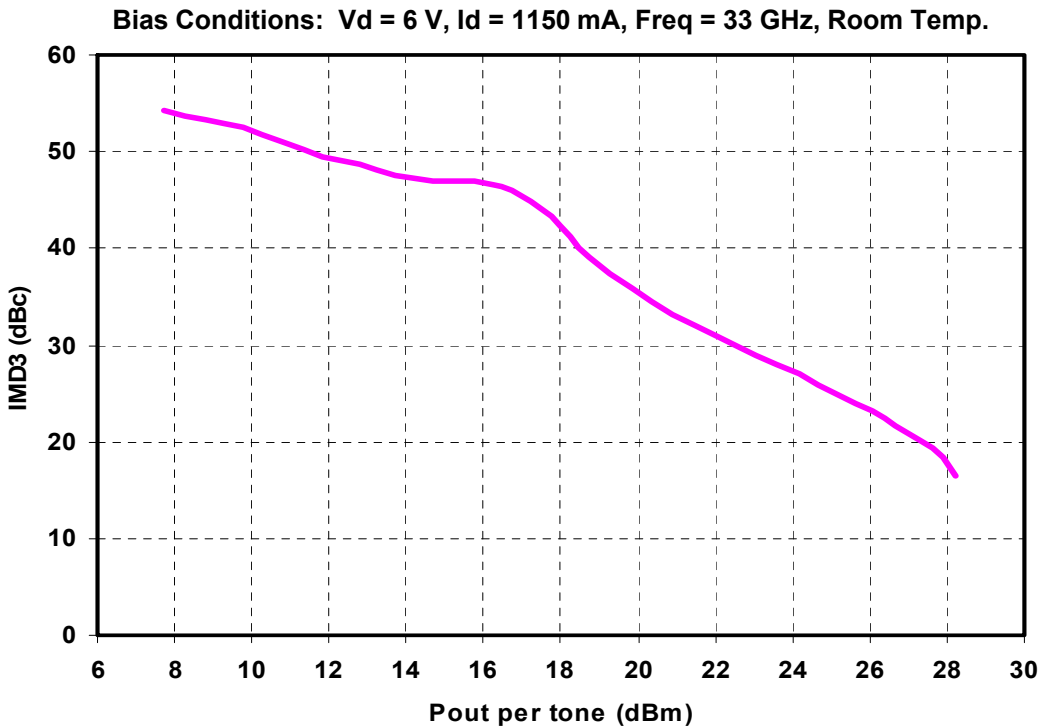
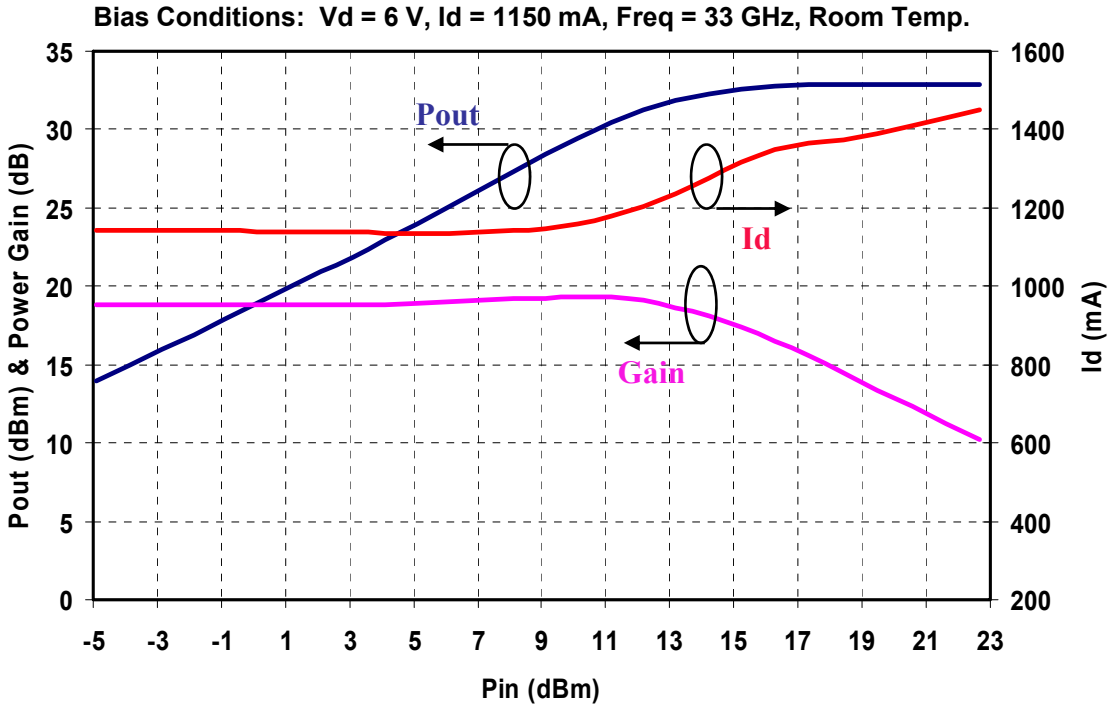
Bias Conditions: $V_d = 6\text{ V}$, $I_d = 1150\text{ mA}$, Room Temp.



Measured Data

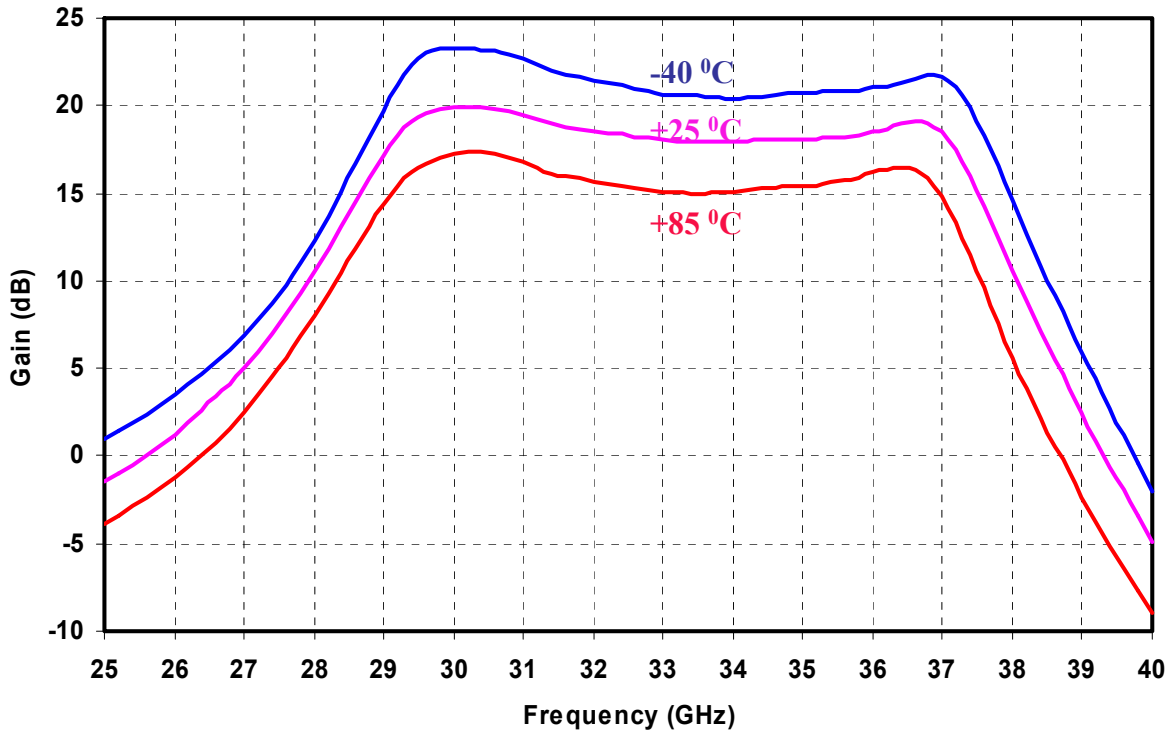


Measured Data

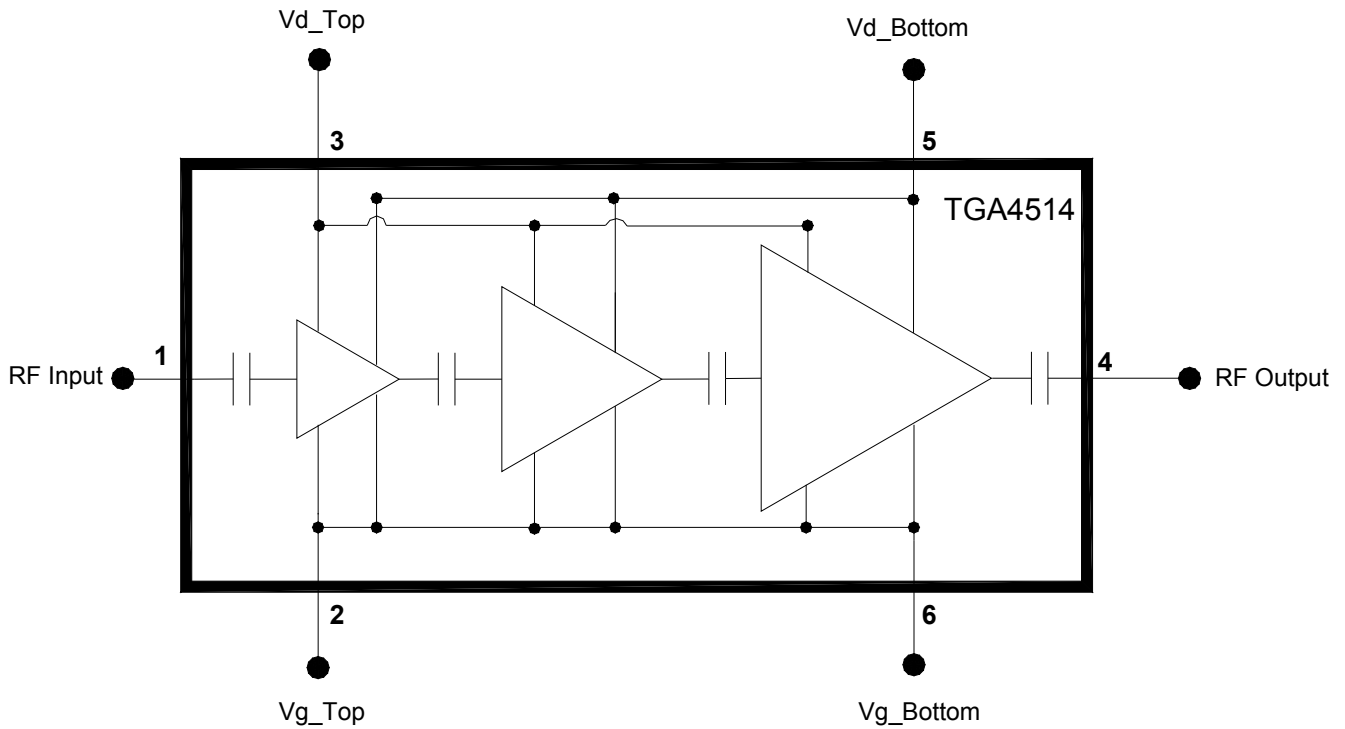


Measured Data

Bias Conditions: $V_d = 6\text{ V}$, $I_d = 1150\text{ mA}$



Electrical Schematic



Bias Procedures

Bias-up Procedure

Vg set to -1.5 V

Vd_set to +6 V

Adjust Vg more positive until quiescent Id is 1115 mA.
This will be ~ Vg = -0.45 V

Apply RF signal to input

Bias-down Procedure

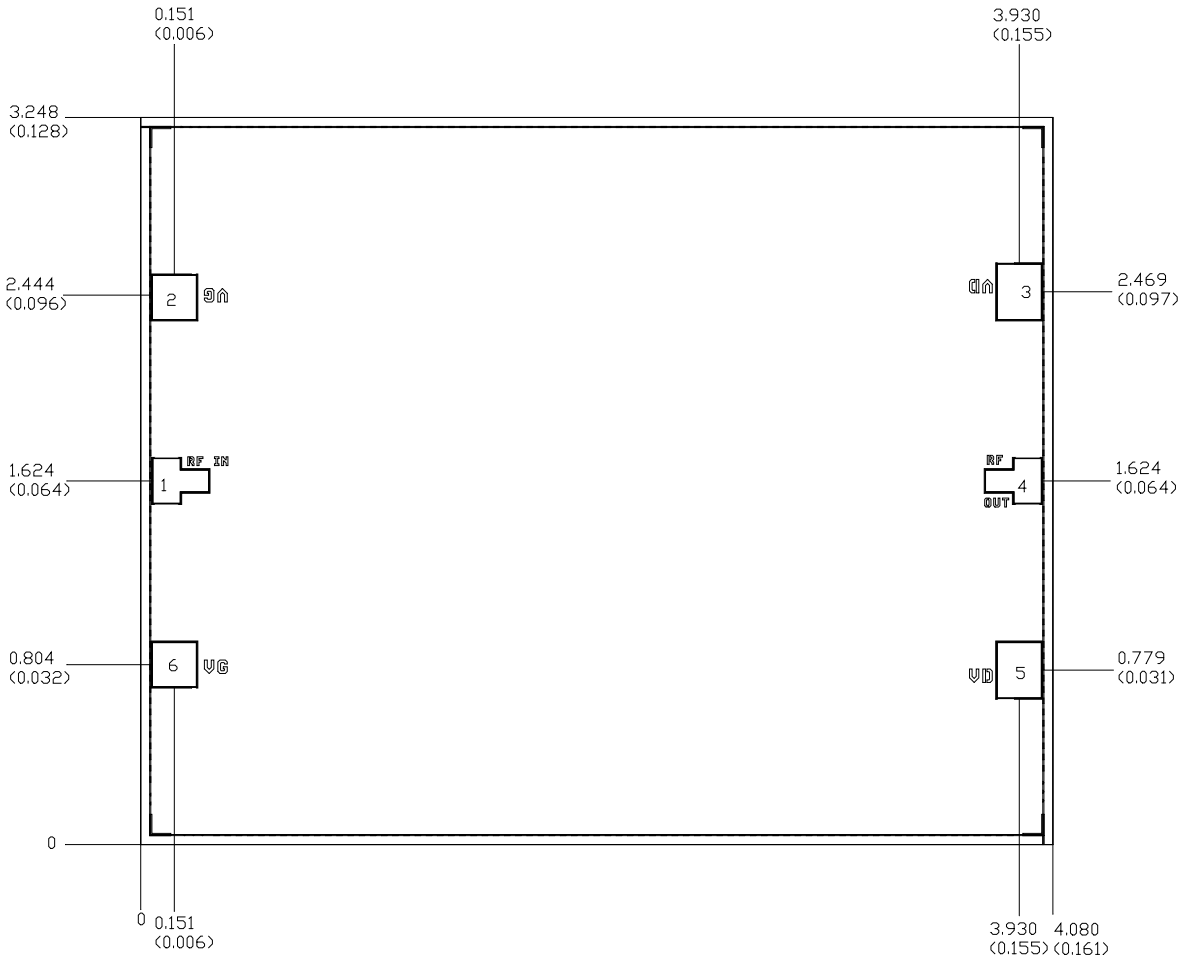
Turn off RF supply

Reduce Vg to -1.5V. Ensure Id ~ 0 mA

Turn Vd to 0 V

Turn Vg to 0 V

Mechanical Drawing

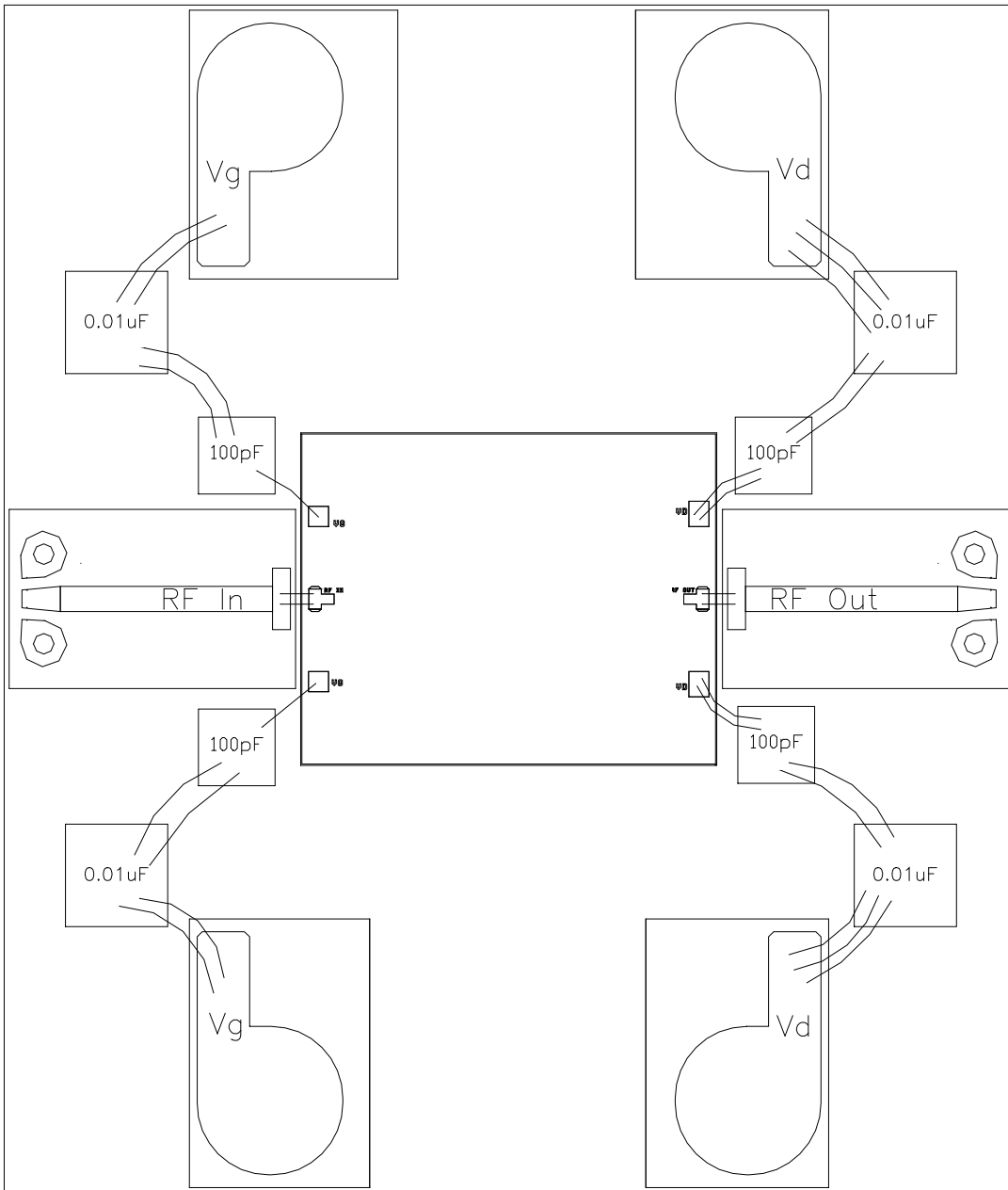


Units: Millimeters (Inches)
 Thickness: 0.100 (0.004)
 Chip edge to bond pad dimensions are shown to center of bond pad
 Chip size tolerance: +/- 0.051 (0.002)
 GND is back side of MMIC

| | | |
|-----------------|----------|-------------------------------|
| Bond pad #1 | <RF In> | 0.135 x 0.210 (0.005 x 0.008) |
| Bond pad #2, #6 | <Vg> | 0.210 x 0.210 (0.008 x 0.008) |
| Bond pad #4 | <RF Out> | 0.135 x 0.210 (0.005 x 0.008) |
| Bond pad #3, #5 | <Vd> | 0.210 x 0.260 (0.008 x 0.010) |

GaAs MMIC devices are susceptible to damage from Electrostatic Discharge. Proper precautions should be observed during handling, assembly and test.

Recommended Assembly Diagram



Note: Apply bias for Vd on both sides. Bias may be applied for Vg from either side.

GaAs MMIC devices are susceptible to damage from Electrostatic Discharge. Proper precautions should be observed during handling, assembly and test.

Assembly Notes

Component placement and adhesive attachment assembly notes:

- Vacuum pencils and/or vacuum collets are the preferred method of pick up.
- Air bridges must be avoided during placement.
- The force impact is critical during auto placement.
- Organic attachment (i.e. epoxy) can be used in low-power applications.
- Curing should be done in a convection oven; proper exhaust is a safety concern.

Reflow process assembly notes:

- Use AuSn (80/20) solder and limit exposure to temperatures above 300°C to 3-4 minutes, maximum.
- An alloy station or conveyor furnace with reducing atmosphere should be used.
- Do not use any kind of flux.
- Coefficient of thermal expansion matching is critical for long-term reliability.
- Devices must be stored in a dry nitrogen atmosphere.

Interconnect process assembly notes:

- Thermosonic ball bonding is the preferred interconnect technique.
- Force, time, and ultrasonics are critical parameters.
- Aluminum wire should not be used.
- Devices with small pad sizes should be bonded with 0.0007-inch wire.

Ordering Information

| Part | Package Style |
|---------|---------------|
| TGA4514 | GaAs MMIC Die |

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